

METHOD FOR THE MANUFACTURE OF A LIQUID CRYSTAL  
DISPLAY

Abstract of the Disclosure

5       The method uses one photomask and one-exposure  
steps wherein said photomask comprising two major  
portions that are formed by mirror image with each other,  
the widths of openings formed in said photomask being  
increased from a central portion to an edge portion, the  
10   spaces between two adjacent said openings being decreased  
from said central portion to said edge. Then, shift said  
substrate with a distance to a direction perpendicular to a  
surface of said photomask. Next, expose said photosensitive  
material layer by using said photomask; and developing the  
15   photosensitive material to form said bump structure